

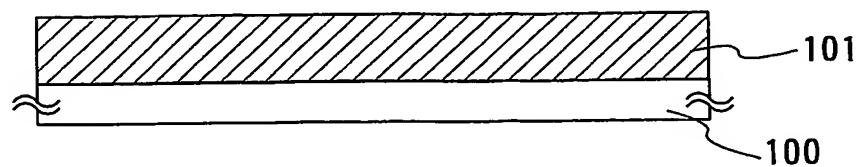
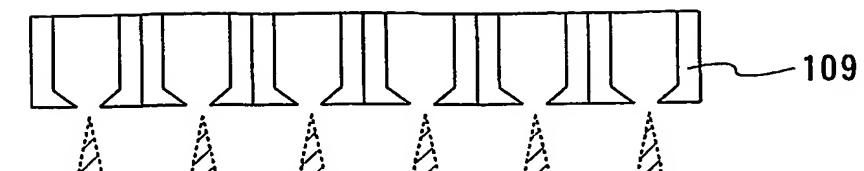
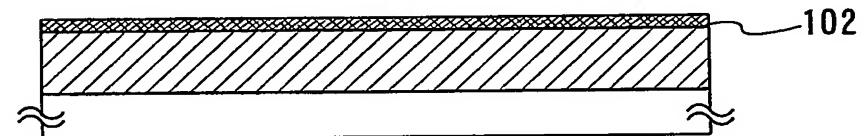
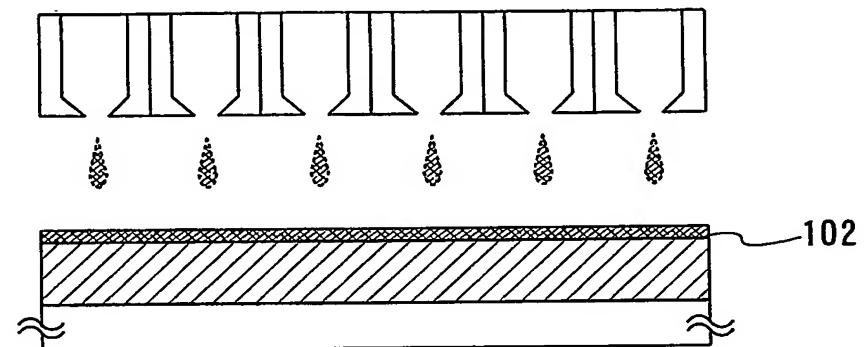
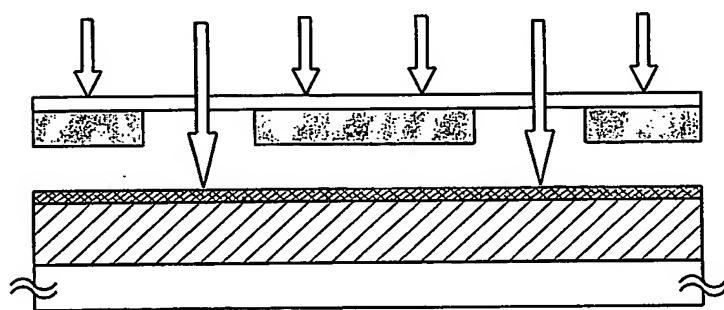
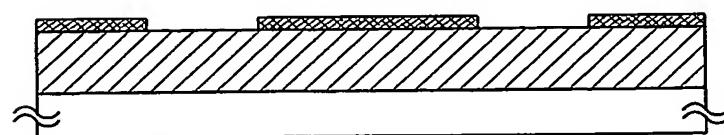
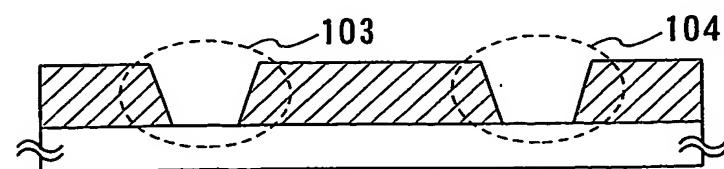
**FIG. 1A****FIG. 1B****FIG. 1C****FIG. 1D****FIG. 1E**

FIG. 2A

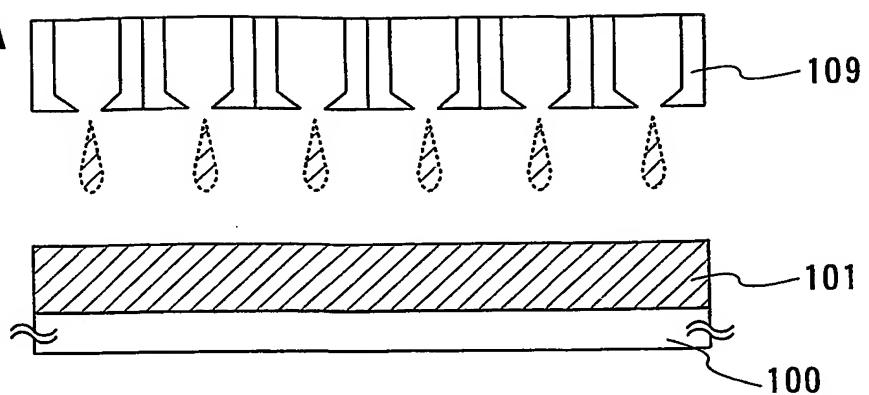


FIG. 2B

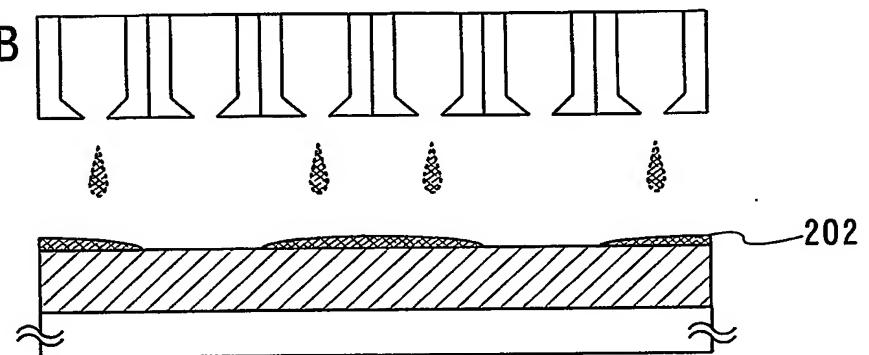


FIG. 2C

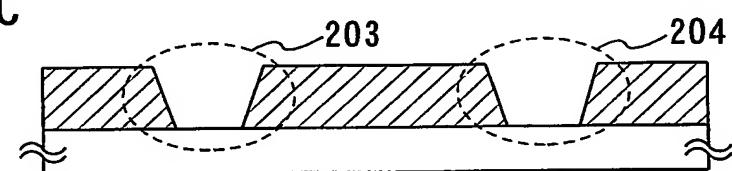


FIG. 2D

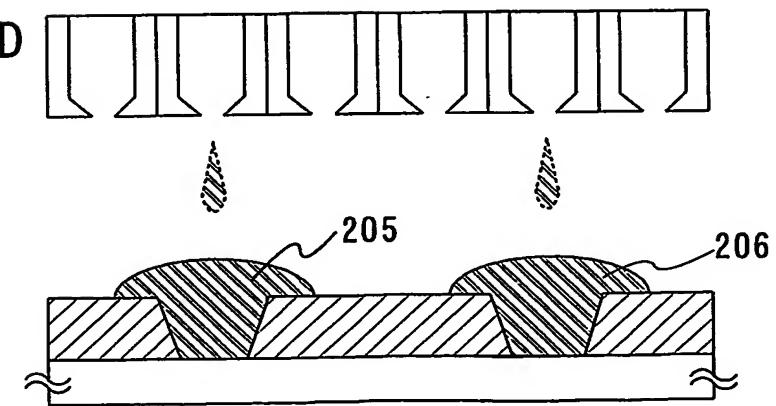


FIG. 3A

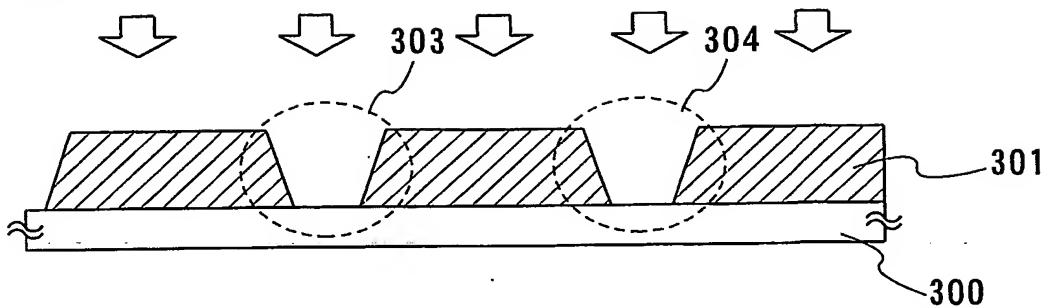


FIG. 3B

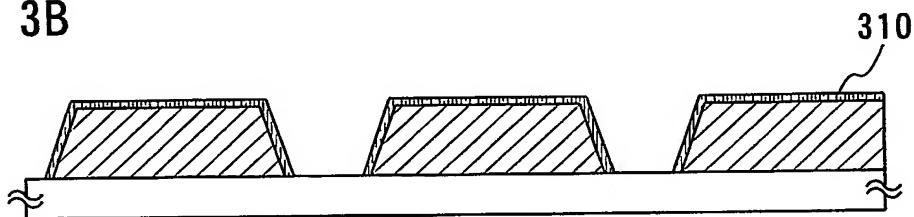


FIG. 4A

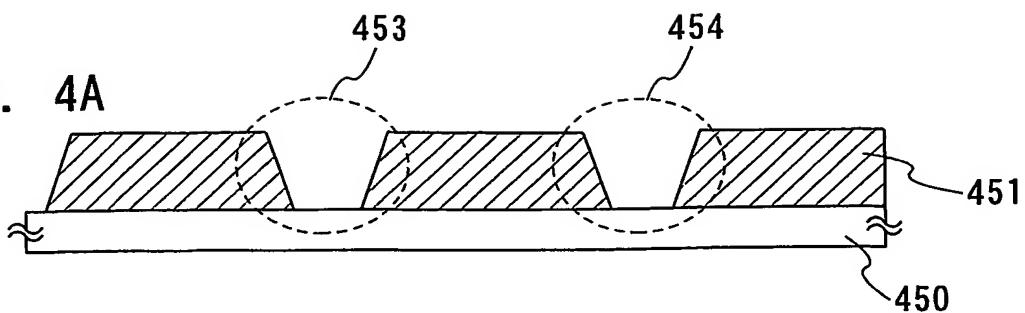


FIG. 4B

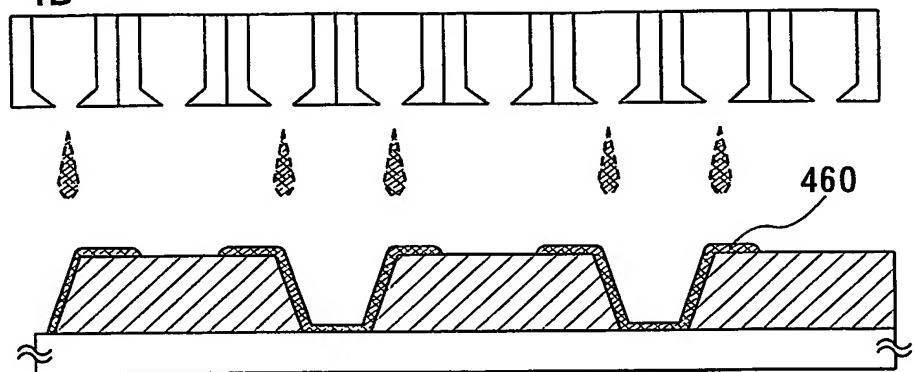


FIG. 5A

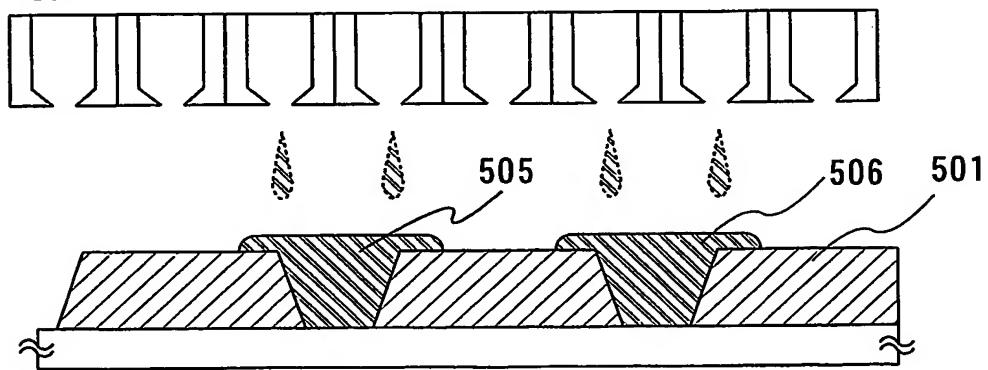


FIG. 5B

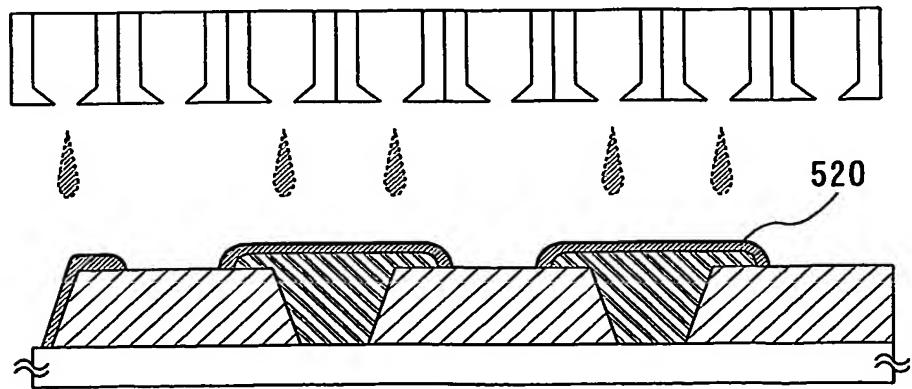


FIG. 6A

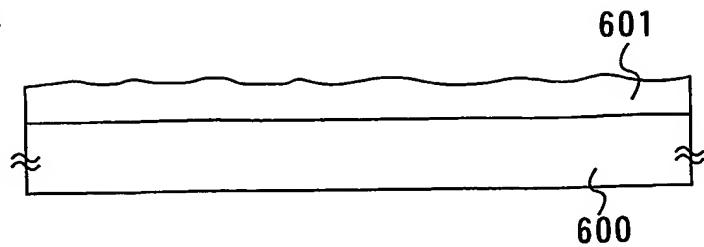


FIG. 6B

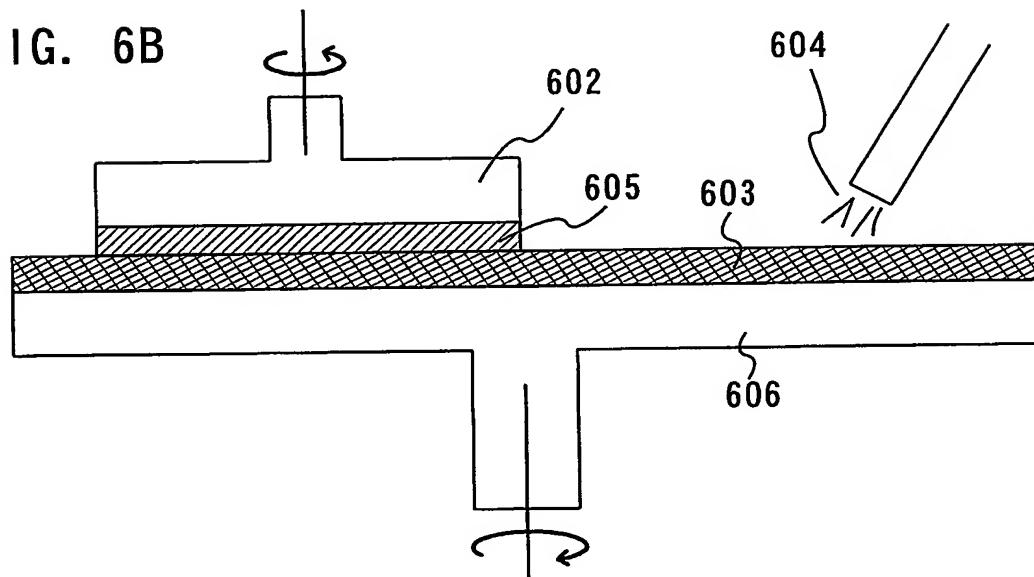


FIG. 6C

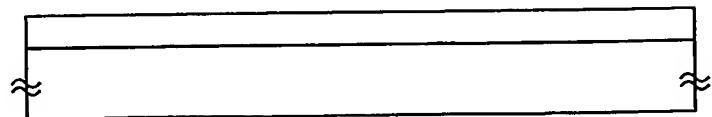


FIG. 7A

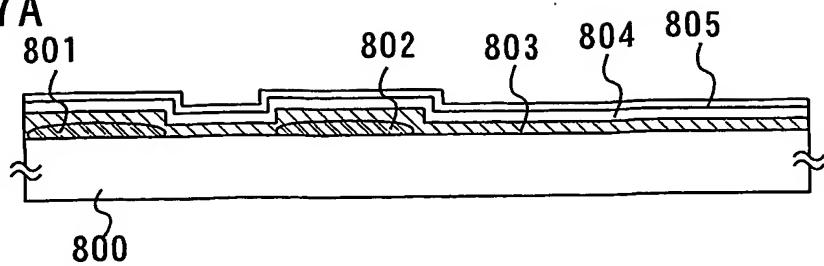


FIG. 7B

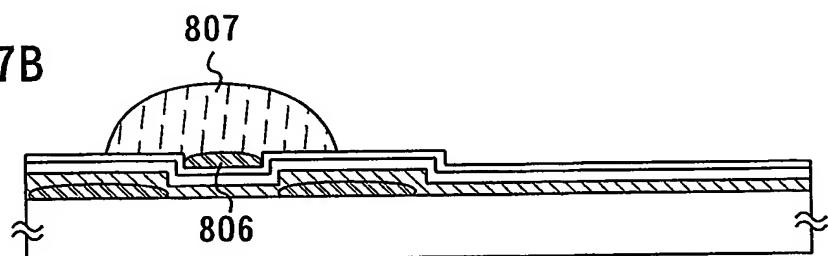


FIG. 7C

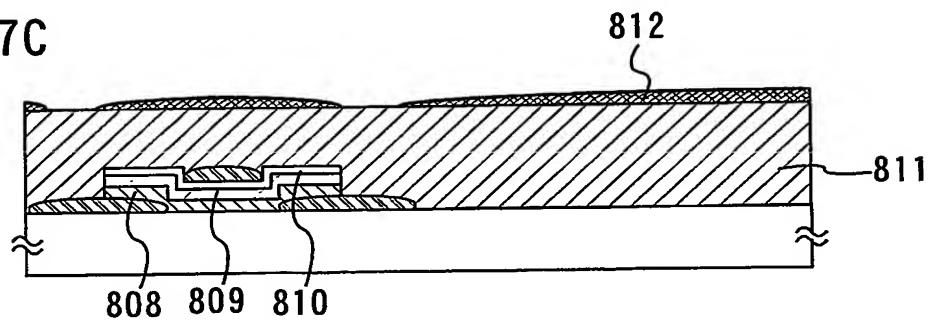
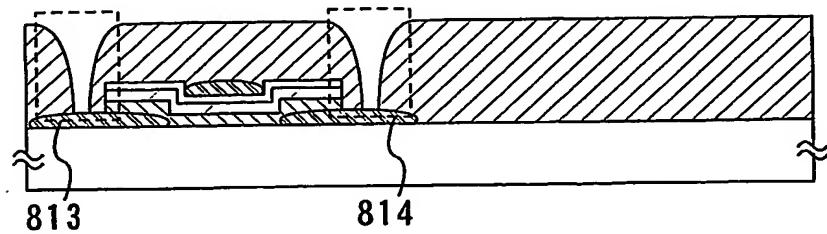


FIG. 7D



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FIG. 8A

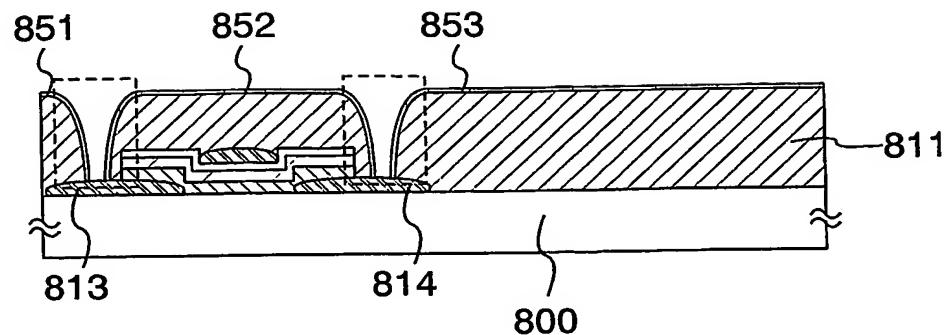


FIG. 8B

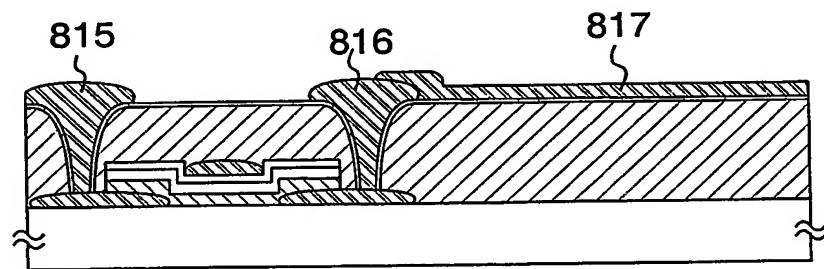
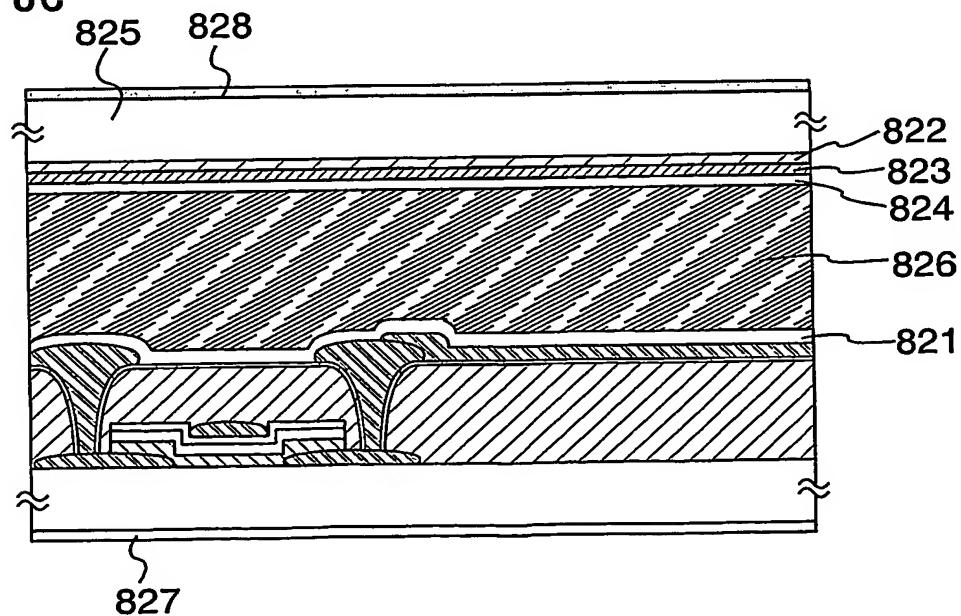


FIG. 8C



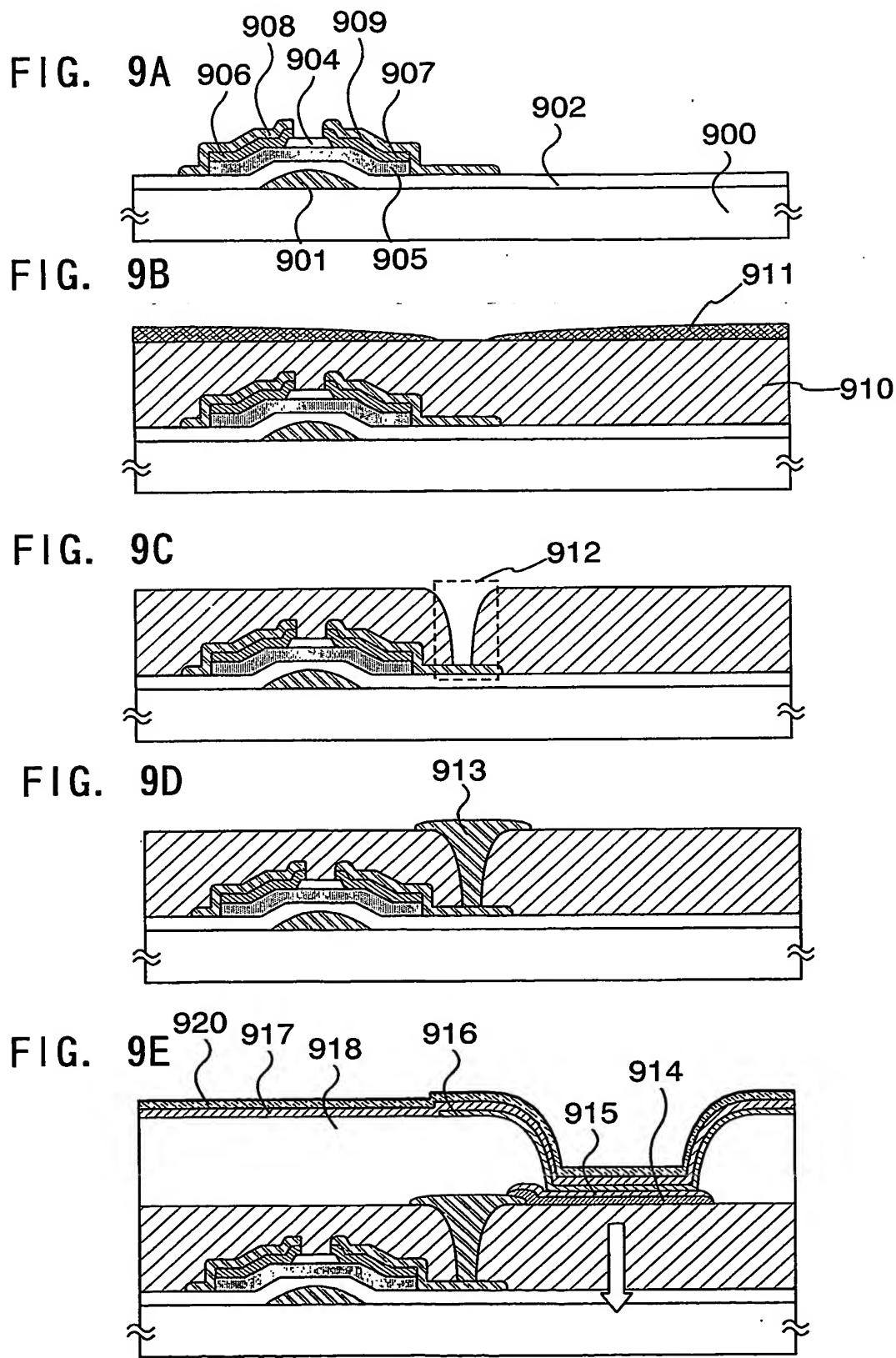


FIG. 10A

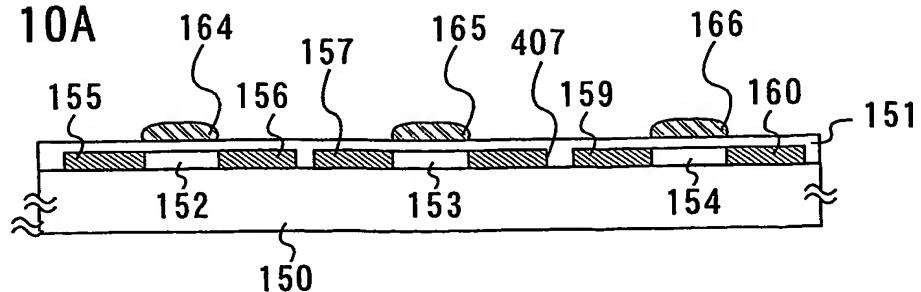


FIG. 10B

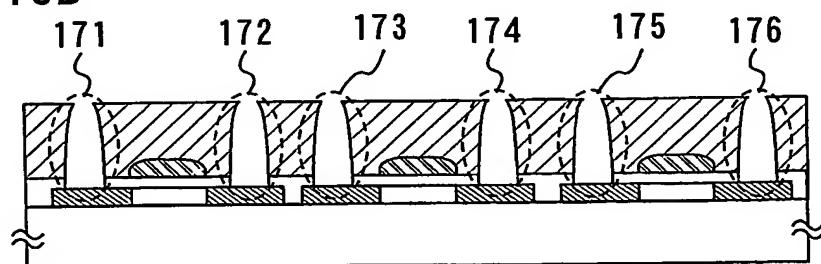


FIG. 10C

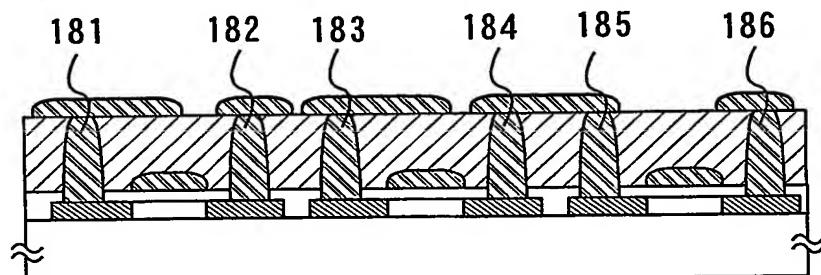


FIG. 10D

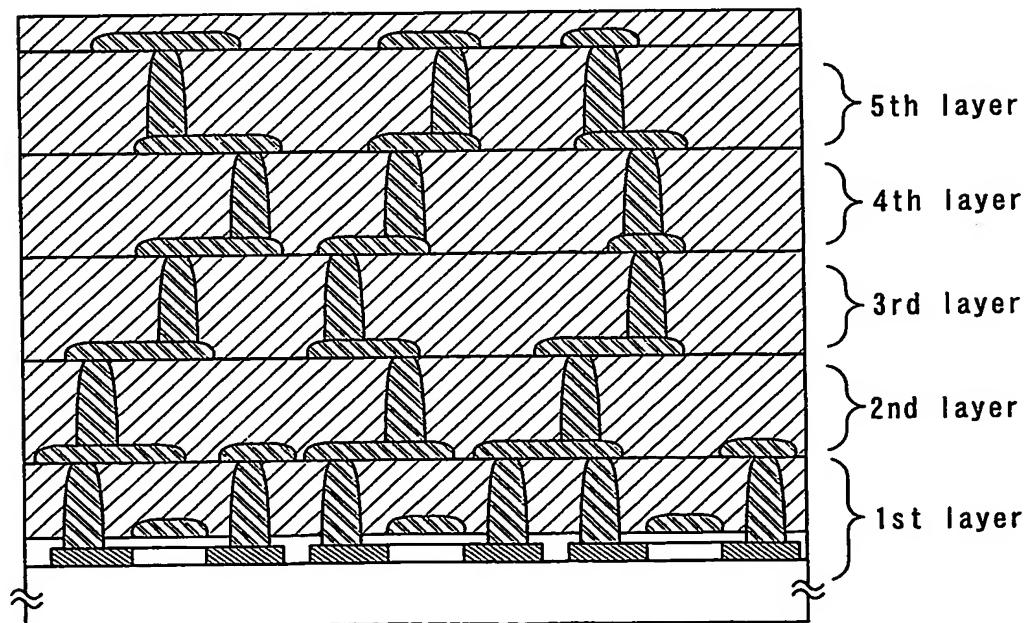


FIG. 11A

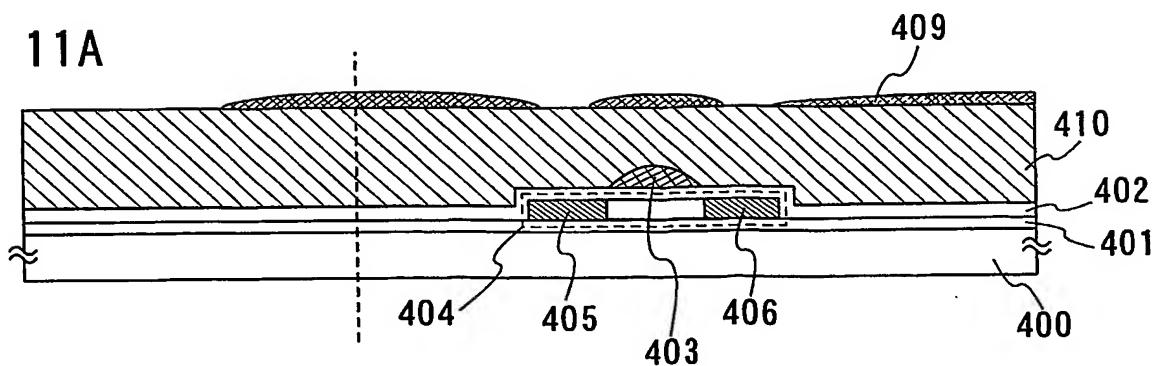


FIG. 11B

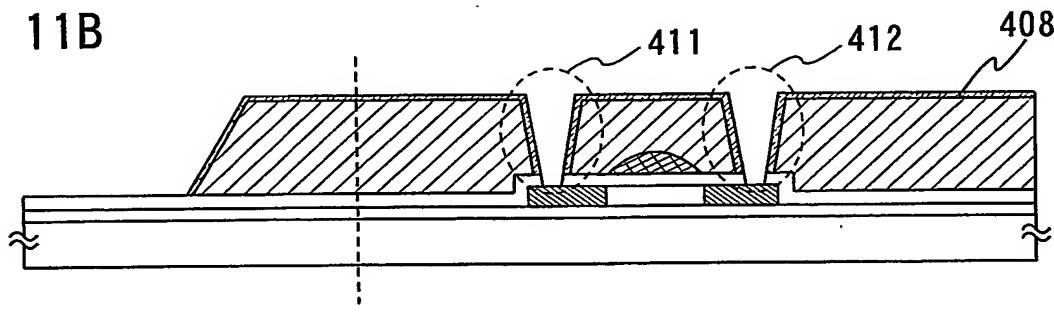


FIG. 11C

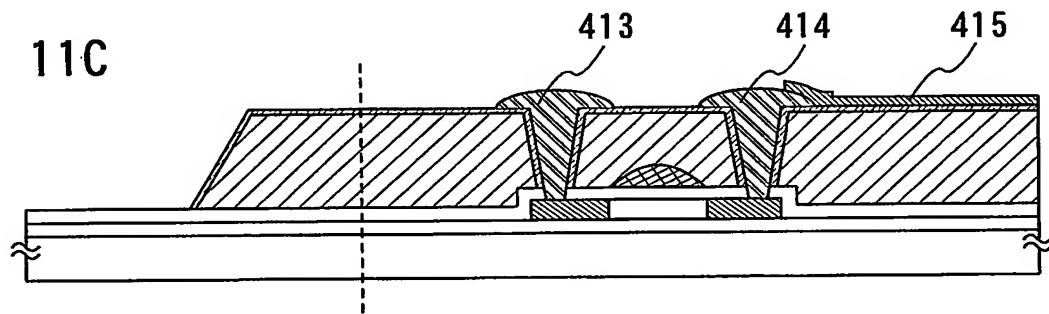
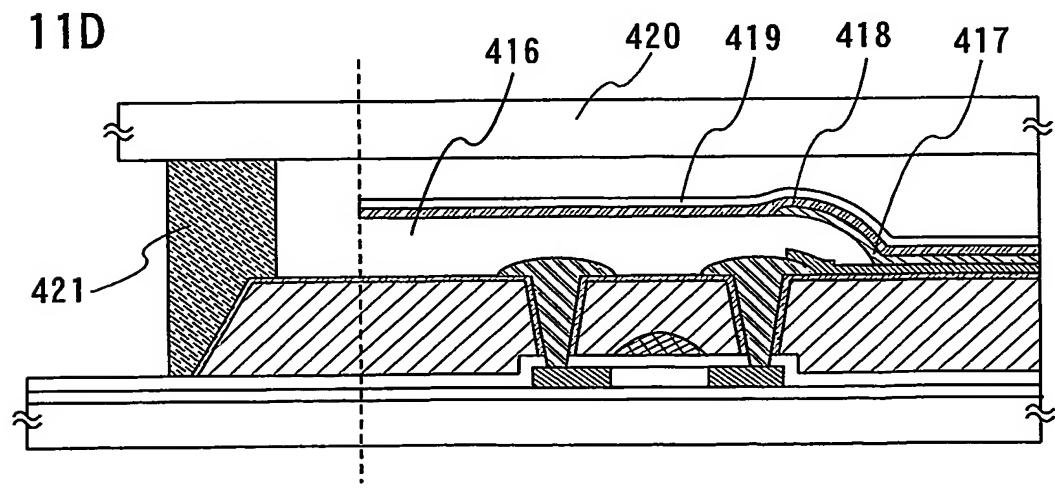


FIG. 11D



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FIG. 12A

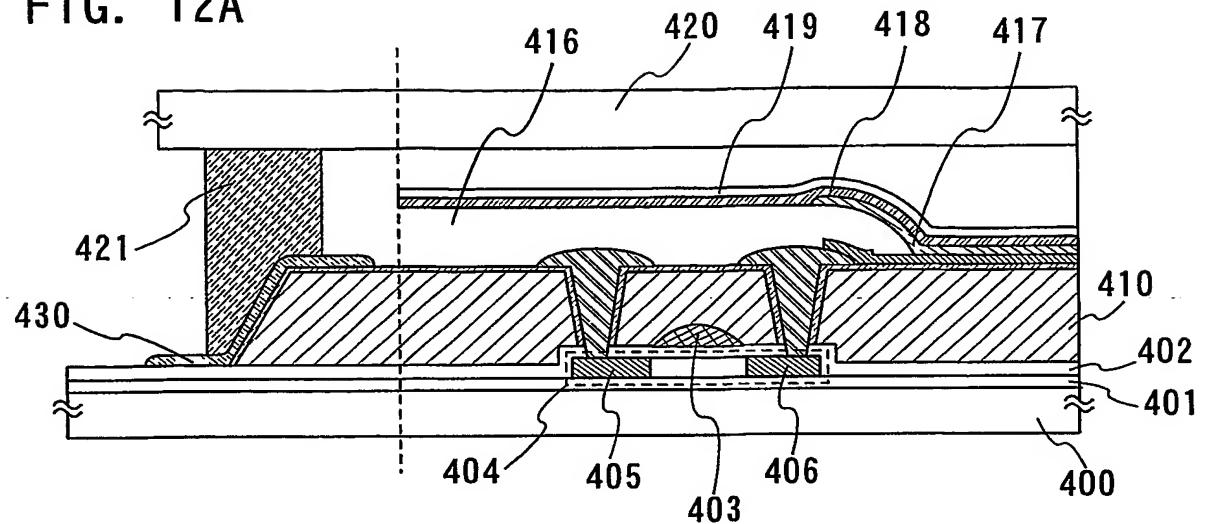


FIG. 12B

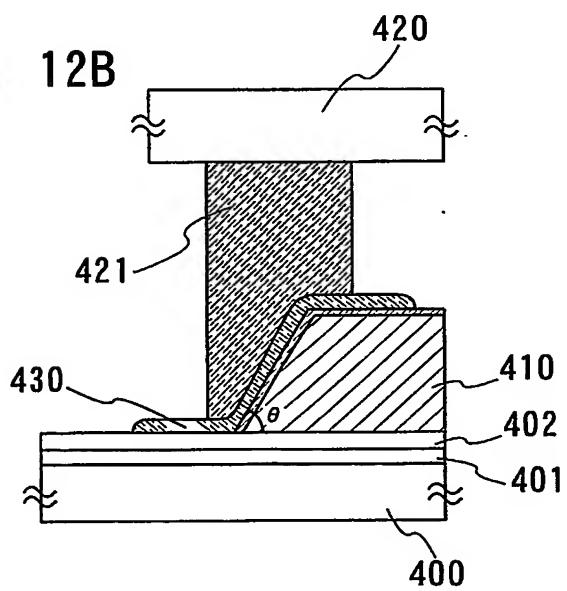


FIG. 13

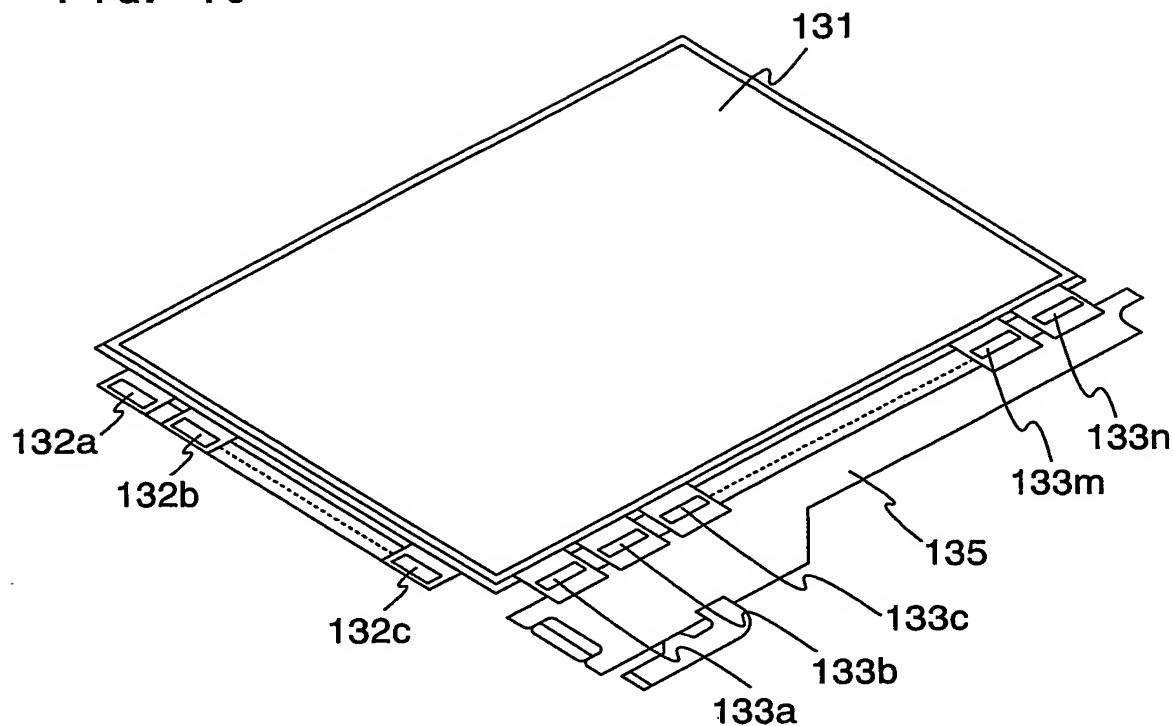


FIG. 14A

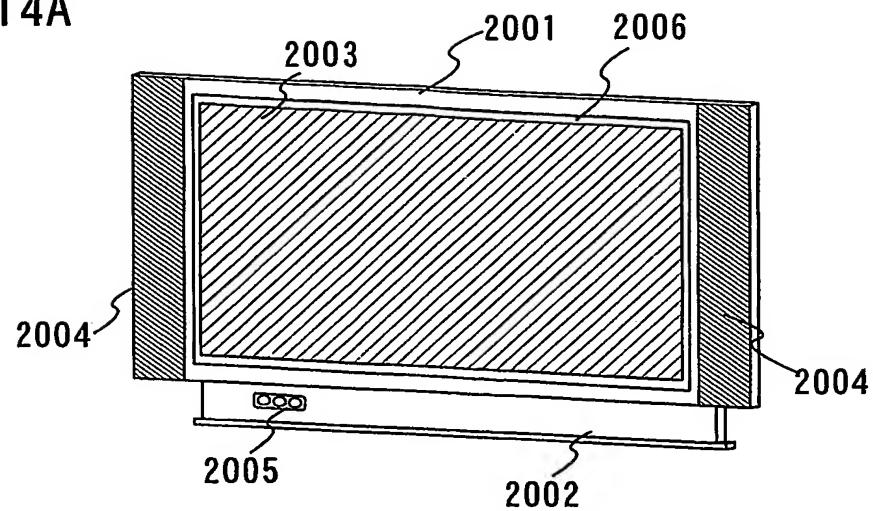


FIG. 14B

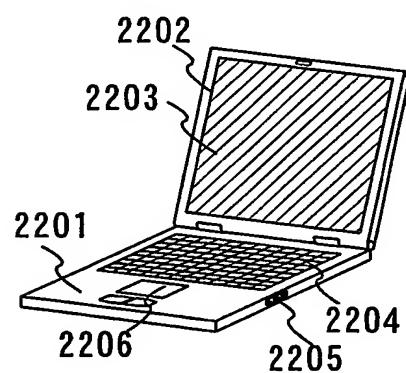
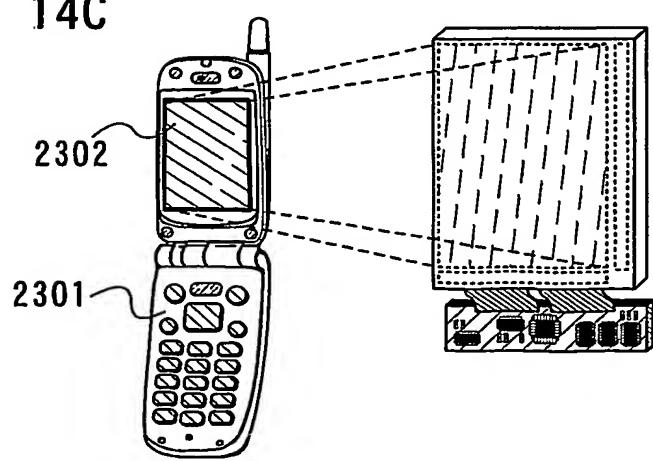


FIG. 14C



EXPLANATION OF REFERENCE

100 · Substrate, 101 · First insulating film, 102 · Second insulating film, 103, 104 · Openings, 202 · Second insulating film, 203, 204 · Openings, 205, 206 · Conductive films, 300 · Substrate, 301 · Insulating film, 303, 304 · Openings, 400 · Substrate, 401 · Base insulating film, 402 · Insulating film, 403 · Gate electrode, 404 · Semiconductor film, 405 · Source, 406 · Drain, 409, 410 · Insulating films, 411, 412 · Openings, 413, 414 · Conductive films, 415 · Pixel electrode, 416 · Bank, 417 · Electroluminescent layer, 418 · Conductive film, 419 · Insulating film, 420 · Substrate, 421 · Sealant, 450 · Substrate, 451 · Insulating film, 453, 454 · Openings, 460 · Barrier layer, 501 · Insulating film, 505, 506 · Conductive films, 520 · Barrier layer, 600 · Substrate, 601 · Insulating film, 602 · Head, 603 · Abrasive cloth, 604 · Abrasive liquid, 605 · Wafer, 606 · Molding board, 800, 825 · Substrates, 801, 802 · Conductive films, 803 · n-type amorphous semiconductor, 804 · Amorphous semiconductor, 805 · Insulating film, 806 · Gate electrode, 807 · Mask, 808 · n-type amorphous semiconductor, 809 · Amorphous semiconductor, 810 · Insulating film, 811, 812 · Insulating films, 813, 814 · Openings, 815, 816 · Conductive films, 817 · Pixel electrode, 821, 824 · Oriented films, 822 · Color filter, 823 · Counter electrode, 824 · Substrate, 826 · Liquid crystal, 827, 828 · Polarizing plates, 900 · Substrate, 901 · Gate electrode, 902 · Insulating film, 905 · Amorphous semiconductor, 906, 907 · n-type amorphous semiconductor, 908, 909 · Conductive films, 910, 911 · Insulating films, 912 · Openings, 913, 914 · Conductive films, 915 · Anode, 916 · Electroluminescent layer, 917, Cathode, 918 · Bank, 920 · Shielding material